

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In the application of:

Masao TOMIKAWA et al.

Serial No. 10/790,800

Filing Date: March 3, 2004

For: POSITIVE PHOTOSENSITIVE RESIN

PRECURSOR COMPOSITION AND PROCESS FOR PRODUCING THE

**SAME** 

Examiner: John S. Y. Chu

Group Art Unit: 1752

## PRELIMINARY AMENDMENT

MS RCE Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Further to the Request for Continued Examination filed concurrently herewith, please amend this application as follows:

The listing of claims begins on page 2.

The Remarks begin on page 7.